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Substitute for form 1449A/PTO SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)				Complete if Known	
				Application Number	10/056,182
				Filing Date	January 24, 2002
				First Named Inventor	Hood et al.
				Art Unit	3725
				Examiner Name	
Sheet	1	of	1	Attorney Docket Number	CRG 005 P2

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U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No. ¹	Document Number Number - Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
GRK		US-5,880,896	03/09/1999	Ishii et al.	
GRK		US-5,861,114	01/19/1999	Roffman et al.	

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OTHER PRIOR ART -- NON PATENT LITERATURE DOCUMENTS			
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T ²
GRK		TOSHISADA TAKAHASHI, NORIYA HAYASHI and SHUNICHI HAYASHI; <i>Structure and Properties of Shape-Memory Polyurethane Block Copolymers</i> ; <i>Journal of Applied Polymer Science</i> ; 1996; Pgs. 1061-1069; Vol. 60; John Wiley & Sons, Inc.	
GRK		BYUNG KYU KIM, SANG YUP LEE and MAO XU; <i>Polyurethanes Having Shape Memory Effects</i> ; <i>Polymer</i> ; 1996; Pgs. 5781-5793; Vol. 37, No. 26; Elsevier Science Ltd.; GB	
GRK		FENGKUI LI, XIAN ZHANG, JIANAN HOU, MAO XU, XIAOLIE LUO, DEZHU MA and BYUNG KYU KIM; <i>Studies on Thermally Stimulated Shape Memory Effect of Segmented Polyurethanes</i> ; <i>Journal of Applied Polymer Science</i> ; 1997; Pgs. 1511-1516; Vol. 64; John Wiley & Sons, Inc.	
GRK		VIERA SKÁKALOVÁ, VLADIMIR LUKEŠ and MARTIN BREZA; <i>Shape Memory Effect of Dehydrochlorinated Crosslinked Poly (Vinyl Chloride)</i> ; <i>Macromol. Chem. Phys.</i> ; 1998; Hüthig & Wepf Verlag, Zug	
GRK		J. R. LIN and L. W. CHEN; <i>Study on Shape-Memory Behavior of Polyether-Based Polyurethanes. I. Influence of the Hard-Segment Content</i> ; <i>Journal of Applied Polymer Science</i> ; 1998; Pgs. 1563-1574; Vol. 69; John Wiley & Sons, Inc.	

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GRK	M. A. RODRÍGUEZ-PÉREZ, DÍEZ-GUTIÉRREZ and J. A. DE SAJA; <i>The Recovery Behavior of Crosslinked Closed Cell Polyolefin Foams</i> ; <i>Polymer Engineering and Science</i> ; 1998; Pgs. 831-837; Vol. 38, No. 5	
GRK	YOSHIHARA KAGAMI, JIAN PING GONG and YOSHIHITO OSADA; <i>Shape Memory Behaviors of Crosslinked Copolymers containing stearyl acrylate</i> ; <i>Macromol. Rapid Commun.</i> ; 1996; Pgs. 539-543; Vol. 17; Hüthig & Wepf Verlag, Zug	
GRK	R. A. MANTZ, P. F. JONES, K. P. CHAFFEE, J. D. LICHTENHAM and J. W. GILMAN; <i>Thermolysis of Polyhedral Oligomeric Silsesquioxane (Poss) Macromers and Poss-Siloxane Copolymers</i> ; <i>Chem. Mater.</i> ; 1996; Pgs. 1250-1259; Vol. 8; American Chemical Society	
GRK	PIYADA CHAROENSIRISOMBOON, HIROMU SAITO, TAKASHI INOUE, YOSHIYUKI OISHI and KUNIO MORI; <i>Polysulfide Containing S-Triazine Rings as a New Thermoplastic Elastomer: Spherulite Morphology and Strain Recovery Behaviour</i> ; <i>Polymer</i> ; 1998; Pgs. 2089-2093; Vol. 39, No. 11; Elsevier Science Ltd., GB	
GRK	M. P. BOGDANOV, S. A. DIMAKOV, A. V. GORLANOV, D. A. GORYACHKIN, A.M. GRIGOR'EV, V. M. IRTUGANOV, V. P. KALINEN, I. M. KLIMENT'EV, I. M. KOZLOVSKAYA, I. B. ORLOVA, V. E. SHERSTOBITOV and V. YU. VENEDIKTOV; <i>Correction of Segmented Mirror Aberrations by Phase Conjugation and Dynamic Holography</i> ; <i>Optic Communications</i> ; 1996; Pgs. 405-413; Vol. 129; Elsevier Science B.V.	
GRK	BYUNG KYU KIM, SANG YUP LEE, JEONG SAM LEE, SANG HYUN BAEK, YOUNG JIN CHOI, JANG OO LEE and MAO XU; <i>Polyurethane Ionomers Having Shape Memory Effects</i> ; <i>Polymer</i> ; 1998; Pgs. 2803-2808; Vol. 39, No. 13; Elsevier Science Ltd.; GB	
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GRK	E. HECHT; <i>Optics, 2nd Ed.</i> ; 1990; Pg. 351; Addison-Wesley; Reading, MA; US	
GRK	RICHARD F. GORDON; <i>Applications of Shape Memory Polyurethanes; Proceedings of First Intn'l. Conference on Shape Memory and Superelastic Technologies</i> ; 1994; Pgs. 115-120	
GRK	H. TOBUSHI, S. HAYASHI and P. H. LIN; <i>Deformation Properties of Polyurethane Shape Memory Polymers</i> ; <i>Proceedings of the First Intn'l. Conference on Shape Memory and Superelastic Technologies</i> ; 1994; Pgs. 109-114	
GRK	<i>Shape Memory Polymers That Resist Creep Better</i> ; <i>High-Tech Materials Alert</i> ; June 2, 2000; John Wiley & Sons, Inc.; US	

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